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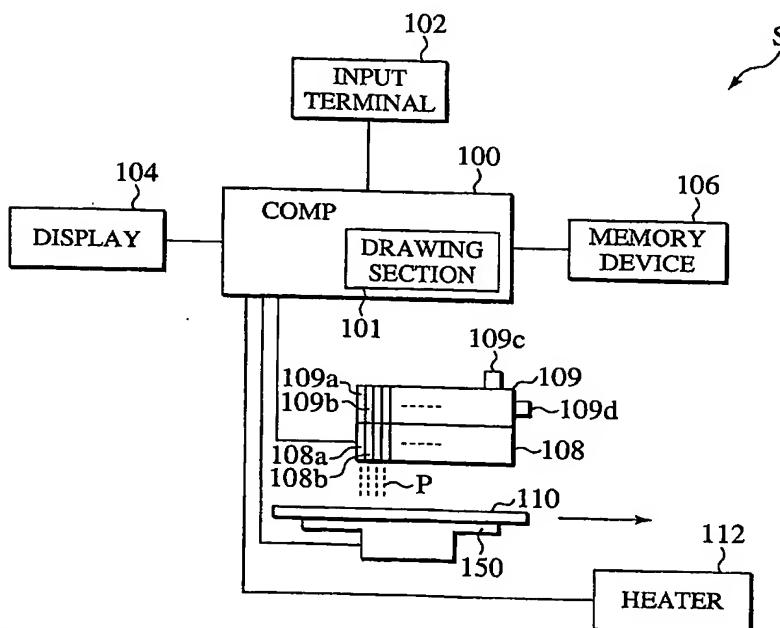
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(54) Title: METHOD OF MANUFACTURING SECONDARY BATTERY ELECTRODE, APPARATUS FOR MANUFACTURING THE SAME AND SECONDARY BATTERY ELECTRODE



(57) Abstract: With a method of manufacturing a secondary battery electrode having active material (111) on a current collector (110), a computer (100) acquires a deposition pattern (PT) for depositing a plurality of kinds of active materials, different in electrical characteristic, onto discrete areas of a current collector, and the computer allows injection nozzles (108) to inject the plurality of kinds of active materials onto the current collector as multiple particles (P), respectively, to be deposited thereon, thereby forming an active layer.



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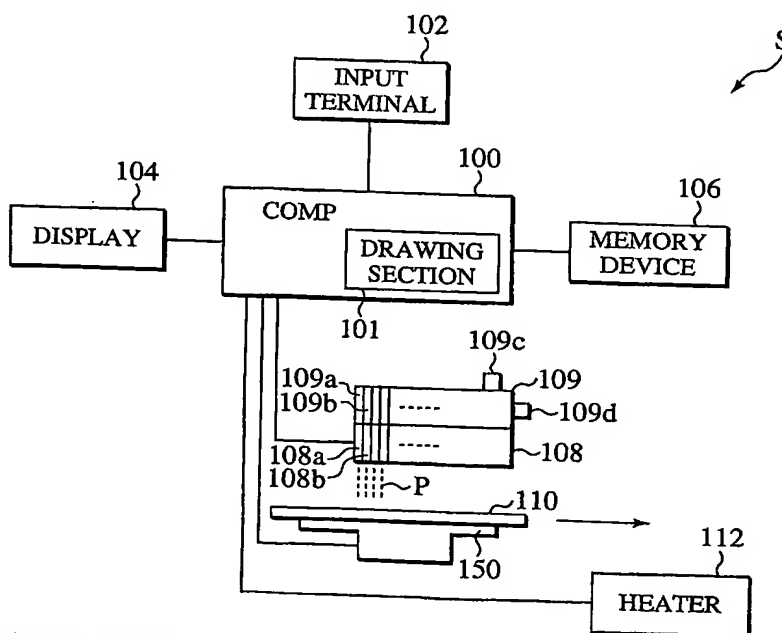
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